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- (74) Common Representative: MERCK PATENT GMBH; Frankfurter Strasse 250, 64293 Darmstadt (DE).
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- (71) Applicant (*for all designated States except US*): MERCK PATENT GMBH [DE/DE]; Frankfurter Strasse 250, 64293 Darmstadt (DE).
- (72) Inventors; and
- (75) Inventors/Applicants (*for US only*): MELLIES, Raimund [DE/DE]; Waldstrasse 63a, 64807 Dieburg (DE). BÖRNER, Marc [DE/DE]; Kiesstrasse 51, 64283 Darmstadt (DE). ARNOLD, Lucia [DE/DE]; Schubertstrasse 10a, 64839 Münster (DE). BARKO, Andrea [DE/DE]; Wendelbergstrasse 6, 63811 Stockstadt (DE). RHEIN, Rudolf [DE/DE]; Niernöller Strasse 7, 64646 Heppenheim (DE).
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(54) Title: COMPOSITION FOR THE REMOVAL OF SIDEWALL RESIDUES

(57) Abstract: The present invention relates to a composition for the removal of so-called "sidewall residues" from metal surfaces, in particular from aluminium or aluminium-containing surfaces, in particular from aluminium or aluminium-containing surfaces, during the production of semiconductor elements.